

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Satoshi Ishikura

Title: SEMICONDUCTOR DEVICE, SEMICONDUCTOR DEVICE DESIGN METHOD, SEMICONDUCTOR DEVICE DESIGN METHOD RECORDING MEDIUM AND SEMICONDUCTOR DEVICE DESIGN SUPPORT SYSTEM

Docket: 31638US4

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. 1.98(d), copies of the references are not enclosed because they were previously cited by or submitted to the Patent Office in U.S. Patent Application Serial No.10/278,496, which application is relied upon for an earlier filing date under 35 U.S.C. 120.

If there are any fees resulting from this communication, please charge said fees to our Deposit Account No. 16-0820, Order No. 31638US4.

Respectfully submitted,

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Date: June 20, 2003

INFORMATION DISCLOSURE CITATION
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Satoshi Ishikura

FILING DATE:

herewithGROUP ART
UNIT:**U.S. PATENT DOCUMENTS**

Examiner Initial	Document No.	Date	Name	Class	Subclass	Filing Date If Appropriate
A	4,656,592	4/1987	Spaanenburg et al.			
B	5,500,542	3/1996	Iida et al.			
C	5,672,895	9/1997	Iida et al.			
D	5,736,772	4/1998	Ko et al.			
E	5,784,291	7/1998	Chen et al.			
F	5,854,752	12/1998	Ararwal			
G	5,955,764	9/1999	Katsume			
H	6,002,155	12/1999	Tahara et al.			
I	6,199,192	3/2001	Marquez et al.			
J	2001/0044925	4/2001	Noguchi			

FOREIGN PATENT DOCUMENTS

	Document No.	Date	Country	Class	Subclass	Translation
K	4/291944 A	10/1992	JP			
L	6-61440 A	3/1994	JP			
M	6-204467	7/1994	JP			
N	6-326248	11/1994	JP			
P	7-235541 A	9/1995	JP			
Q	8-306922	11/1996	JP			
R	8-339392	12/1996	JP			

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

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Examiner:

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*Examiner: Initial if reference considered, regardless of whether citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.